Evaluation of On-line Derivatization Techniques Using TMAH and HMDS for the Comprehensive Analysis of Anacardiaceae Thermosetting Lacquer Polymers Using **Pyrolysis-GC/MS and Deconvolution**

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INTRODUCTION

Asian lacquers are complex natural thermosetting polymers, used since prehistory to decorate and protect objects, weapons and even architecture. There are 3 predominant types, which can be harvested from different trees in Asia (Figure 1). In the context of our current research the comprehensive identification presents many challenges and obstacles, mainly because of the insolubility of the complex polymeric matrix and stability of the chemical bonds. Pyrolysis coupled to gas chromatography/mass spectrometry is currently the most suitable technique for analysis through thermal fragmentation of the solid lacquer polymer into gas phase molecules amenable to GC separation. However, problems that can emerge in analytical pyrolysis are related to the low volatility of acidic, alcoholic and amidic pyrolytic products, which can cause poor reproducibility, low sensitivity, bad peak shapes and memory effects, making derivatization a necessity. In a broader context of safe and effective cleaning solutions on cultural heritage objects, this contribution critically evaluates a Thermally Assisted Hydrolysis and Methylation (THM) method with Tetramethyl ammoniumhydroxyde (TMAH) and a silylation method after pyrolysis using hexamethyldisilazane (HMDS) reagent.

RESULTS AND DISCUSSION

Table II: Overview of the markers

Derivatization	Marker	Marker name	RT	Fragment ions (m/z)
туре	nr.		(min)	
None	1	Benzene, decyl	9.38	43, 57, 91, (218)
None	2	Benzene, dodecyl	10.96	43, 57, 91, (246)
ТМАН	3	Hexadecanoic acid, methyl ester	11.20	74, 143, 227, (270)
HMDS	3a	Hexadecanoic acid, TMS derivate	11.85	74, 117, 145, (313)
ТМАН	4	Octadecanoic acid, methyl ester	12.57	74, 143, 255, (298)
HMDS	4a	Octadecanoic acid, TMS derivate	13.13	74, 117, 145, (341)
ТМАН	5	Methyl 8-(2,3-dimethoxyphenyl)octanoate	12.75	91, 136, 151, (294)
ТМАН	6	Methyl 13-phenyl-tridecanoate	13,92	91, 104, 163, 272
HMDS	6a	13-phenyl-tridecanoate, TMS derivate	13.78	91, 179,
HMDS	7	12-phenyl-dodecanoate, TMS derivate	13.81	73, 91, 117, (333)
ТМАН	8	1,2-Dimethoxy-3-pentadecylbenzene	15.34	91, 136, 151, (348)
HMDS	8a	3-pentadecylcatechol, TMS derivate	15.87	73, 179, 376, (392)
HMDS	8b	3-pentadecylcatechol, 2TMS derivate	16.23	73, 179, 450, (464)
ТМАН	9	1,2-Dimethoxy-10-phenyldecylbenzene	17.19	91, 136, 152, (354)
HMDS	9a	2-(10-phenyldecyl)-phenol, TMS derivate	16.47	73, 180, 205, (382)
HMDS	9b	4-(10-phenyldecyl)-catechol, 2TMS derivate	17.98	91, 193, 267, (470)
ТМАН	10	1,2-Dimethoxy-12-phenyldodecylbenzene	19.05	91, 136, 151, (382)
HMDS	10a	3-(12-phenyldodecyl)-catechol, TMS derivate	19.64	73, 91, 179, (426)



Figure 1: Geographic origin of three mayor types of Asian lacquer. T. vernicifluum, T. succedanea and Melanorrhoea (Gluta) usitata consisting respectively of main polymeric compounds of urushiol, laccol and thitsiol.

BACKGROUND



Urushiol $R = C_{15}H_{25-31}$



Figure 2: Polymerization mechanisms of urushiol catalyzed by laccase.

Previous research has shown the main pyrolytic pathways that lead to the formation of series of cathechols, phenyl cathechols, phenols and alkylbenzenes marker compounds in Anacard lacquers. For each serie, there is maximum alkyl side chain length, which can hence be related to the corresponding lacquer type. In T. vernicifluum, cathechols and hydrocarbons with a maximum C15 side chain, C7 being as it's most abundant member is identified. C17 side chains, with C8 as the most persistent member is found in *T. succedaneum* lacquer. Likewise, phenyl cathechols, phenyl phenols and alkyl benzenes are unique markers for G. usitata. The significant advantage of using TMAH as a methylating reagent or HMDS for silulation of the compounds is that it allows for the identification of series of successive marker compounds formed through aging and consequent oxidation. Methyl 8-(2,3-dimethoxyphenyl)octanoate is for example the dominant marker identified in T. vernicifluum and G. usitata lacquers. In T. succedaneum Methyl 10-(2,3dimethoxyphenyl)decanoate is the most abundant member. Those markers, termed acid cathechols, form, from oxidation reactions along the alkenyl side chain of the substituted cathechols. Methyl 13phenyl-tridecanoate is a representative compound of a serie of aging products that can be found in G.usitata lacquer, which forms from the oxidation of the unsaturated side chains of alkenyl benzenes.



Characteristic marker molecules in Asian lacquer, produced by pyrolysis through cleavage of C-C bonds generally display large amounts of hydroxyl groups and carboxylic acid functionalities, e.g. phenols, catechols, fatty acids and acid catechols-). To overcome issues during the GC/MS run such as peak broadening, memory effects and poor reproducibility, derivatization is needed to improve the analysis. The use of thermally assisted reactions with TMAH has demonstrated positive results for lacquers and related materials. As a consequence of its strong alkalinity TMAH cleaves hydrolysable bonds and deprotonates acidic groups. The excess of TMAH is thermally decomposed to methanol and dimethyl ether. The methyl derivative of the acid and trimethylamine remains as a side product.

R-COOH

$R-COOSi(CH_3)_3 + H_2NSi(CH_3)_3$

Despite the good results with TMAH, its strong alkalinity can generate side-reactions, which might complicate the analysis, such as decarboxylation reactions, isomerisation or the formation of dehydration products. An alternative, which has already been succesfully used by several laboratories is silulation after pyrolysis with HMDS, which is a relatively weak trimethylsilyl donor. After pyrolysis active hydrogen is replaced with a trimethylsilyl group (TMS). In this study both techniques are evaluated based on yield/efficiency of specific markers and reproducibility of the







Figure 3: Plotted peak areas @ experimental pyrolysis temperatures.

EXPERIMENTAL

Table I: Experimental procedures

Instrumentation	Methods
EGA/PY-3030D Multi-Shot Pyrolyzer (Frontier Laboratories)	Flash pyrolysis of 80µg ground lacquer films + 3µL derivatization reagent + C13:0 IS at fixed pyrolysis temperatures ($300^{\circ}C \div 700^{\circ}C$) and Ultrafast Thermal desorption (UTD) $350^{\circ}C$ - $668^{\circ}C$ @0.90m. Interface was set at 290°C
Trace 1310 Gas Chromatograph (Thermo Scientific)	Fused slilica SLB-5MS capillary column (Supelco, 20 m, 0.18 mm i.d. x 0.18µm film thickness, silphenylene polymer stationairy phase) Constant carrier gas flow (He) of 0,9ml min1 Split 1:30 (1 min) Injector temperature: 300°C GC oven: Initial 35°C (1.50 min hold), 60°C/min ramp → 100°C. 14°C/min ramp → 250°C- 6°C/min ramp → 315°C- 1.50 min iso-thermal.
ISQ LT Single Quadrupole Mass Spectrometer (Thermo Scientific)	MS transfer line @ 270°C. Solvent delay @ 1.10m Ionization @70eV positive ion mode MS was scanned @ 29-600 amu, with a cycle time of 0.2sec.

Above analyses were performed in trifold .The bar graphs display the averages and error bars. Both methods show a similar pyrolysis temperature optimum between 450C-550C. However, the analyses with TMAH derivatization display a better yield. Looking at the relative standard deviation (RSD) the TMAH 5% method performs better as well with rsd's typically below 10%, for most components. For HMDS (3µL volume), this is generally 60-80%. Increasing the TMAH concentration does not affect peak areas, however reproducibility increases, with typical rsd's below 5% using TMAH 10%. The concentration of HMDS could only be increased by adding more volume, up to 5µL. This had only a minor effect on reproducibility and no effect on peak areas.

CONCLUSION

Pyrolysis temperature optimum lies between 450C-550C. The TMAH derivatization method shows generally better results in this study, both in terms of qualitative yield and in reproducibility. However, the measurements in this study were performed in trifold and larger data sets could provide a more exhaustive result. Increasing the concentration or total volume for both methods does only affect lowering the rsd's

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